

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

RADEMARKS	Δ.
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE	
In re application of	ENT AND TRADEMARK OFFICE Confirmation No. 4175 Docket No. 2001-1787A Group Art Unit 1752
Hideo HADA et al.	: Docket No. 2001-1787A
Serial No. 09/996,676	: Group Art Unit 1752
Filed November 30, 2001	: Examiner R. Ashton
POSITIVE-WORKING PHOTORESIST COMPOSITION	
DECLARATION	
Assistant Commissioner for Patents, Washington, D.C.	
Sir:	
I, Nobue KANAKA	declare and say:
that I am thoroughly conversant in both the Japanese and English languages;	
that I am presently engaged as a translator in these languages,	
that the attached document represents a true English translation of the Japanese Priority	
Application No. 2000-369225, filed December 4, 2000.	
I further declare that all statements made herein of my own knowledge are true and that all	
statements made on information and belief are believed to be true; and further that these statements	
were made with the knowledge that willful false statements and the like so made are punishable by	

fine or imprisonment, or both, under Section 1001 of Title 18 of the United States Code, and that

such willful false statements may jeopardize the validity of the application or any patent issuing

Signed this 12th day of fune, 2003.

thereon.